

PATENT

**RESPONSE UNDER 37 C.F.R. 1.116 - EXPEDITED
PROCEDURE - EXAMINING GROUP 2891**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No.: 10/808,692 Confirmation No.: 6062
Applicant(s): Ogihara et al.
Filed: 03/25/2004
Art Unit: 2891
Examiner: A. Sarkar
Title: COMPOSITION FOR FORMING POROUS FILM, POROUS FILM
AND METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR
FILM AND SEMICONDUCTOR DEVICE

*Do not
enter
AKS
5/25/06*

Docket No.: 035576/276101
Customer No.: 00826

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY AFTER FINAL UNDER 37 CFR § 1.116

Sir:

In response to the final Office Action dated March 20, 2006, please consider the following remarks:

Remarks/Arguments begin on page 2 of this paper.